Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
11	381	(etching adj hole) near5 (passivation or insulating or dielectric)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/24 13:22
L2	<b>48</b>	((etching adj hole) near5 (passivation or insulating or dielectric)) and ((etching adj hole) near5 (seal or sealing or pattern or patterning or patterned))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/24 13:23
L3	2	((etching adj hole) near5 (passivation or insulating or dielectric)) and ((etching adj hole) near5 (seal or sealing or pattern or patterning or patterned)) and (lcd or (liquid adj crystal))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/24 13:23
L4		((etching adj hole) near10 (passivation or insulating or dielectric)) and ((etching adj hole) near5 (seal or sealing or pattern or patterning or patterned)) and (lcd or (liquid adj crystal))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/24 13:26
L5	2	((etching adj hole) near10 (passivation or insulating or dielectric)) and ((etching adj hole) near5 (seal or sealing or sealed)) and (lcd or (liquid adj crystal))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/24 13:25
L6	2	((etching adj hole) near10 (passivation or insulating or dielectric)) and ((etching adj hole) near10 (seal or sealing or sealed)) and (lcd or (liquid adj crystal))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/24 13:25
L7	2	(((etch or etching) adj hole) near10 (passivation or insulating or dielectric)) and ((etching adj hole) near10 (seal or sealing or sealed)) and (lcd or (liquid adj crystal))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/24 13:26
L8	2	(((etch or etching) adj hole) near10 (passivation or insulating or dielectric)) and (((etch or etching) adj hole) near10 (seal or sealing or sealed)) and (lcd or (liquid adj crystal))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/24 13:26
L9	2	(((etch or etching) adj hole) with (passivation or insulating or dielectric)) and (((etch or etching) adj hole) near10 (seal or sealing or sealed)) and (lcd or (liquid adj crystal))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/24 13:26

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L10	2	(((etch or etching) adj hole) with (passivation or insulating or dielectric)) and (((etch or etching) adj hole) with (seal or sealing or	US-PGPUB; USPAT; EPO; JPO; DERWENT;	OR	ON	2004/11/24 13:26
		sealed)) and (Icd or (Iiquid adj crystal))	IBM_TDB			
L11	2	(((etch or etching) adj hole) with (seal or sealing or sealed)) and (lcd or (liquid adj crystal))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/24 13:26
L12	8	((etching adj hole) near10 (passivation or insulating or dielectric)) and ((etching adj hole) near10 (seal or sealing or pattern or patterning or patterned)) and (lcd or (liquid adj crystal))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/24 13:26
L13	8	(((etch or etching) adj hole) near10 (passivation or insulating or dielectric)) and ((etching adj hole) near10 (seal or sealing or pattern or patterning or patterned)) and (lcd or (liquid adj crystal))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/24 13:27
L14	8	(((etch or etching) adj hole) near10 (passivation or insulating or dielectric)) and (((etch or etching) adj hole) near10 (seal or sealing or pattern or patterning or patterned)) and (lcd or (liquid adj crystal))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/24 13:27
L15	2	(((etch or etching) adj hole) near10 (passivation or insulating or dielectric)) and (((etch or etching) adj hole) near10 (seal or sealing or pattern or patterning or patterned)) and (lcd or (liquid adj crystal)) and (seal or sealing or sealed or sealant)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/24 13:27